IN THE CLAIMS

Please amend the claims as follows:

Claim 1 (Previously Presented): A substrate processing apparatus comprising:

a processing chamber for accommodating a substrate therein;

a mounting table for mounting the substrate thereon;

a heating member disposed in the mounting table, for heating the substrate;

a sealing member disposed between a bottom of a support of the mounting table and a

bottom portion of the processing chamber; and

a cooling unit, having a cooling medium, for cooling the sealing member by using a

latent heat of vaporization of the cooling medium included therein, wherein the cooling unit

includes an airtight casing for accommodating the cooling medium therein, the casing has a

first end portion and a second end portion, and the first end portion is configured to be

inserted into an opening formed through the bottom portion of the processing chamber,

wherein the cooling unit further includes a condenser accommodating therein the

second end portion to thereby liquefy, in the second end portion, the cooling medium

vaporized in the first end portion.

Claim 2 (Previously Presented): The apparatus of claim 1, wherein the casing is

depressurized.

Claim 3 (Original): The apparatus of claim 1, further comprising a temperature

sensor disposed near the sealing member and a cooling unit controller for controlling the

cooling unit based on a measurement result of the temperature sensor.

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Claim 4 (Original): The apparatus of claim 1, further comprising a processing gas supply system for supplying a processing gas into the processing chamber.

Claim 5 (Original): The apparatus of claim 4, wherein the processing gas supply system includes a plurality of processing gas supply units for supplying different processing gases and a processing gas supply unit controller for controlling each of the processing gas supply units such that the processing gases are supplied alternately.

Claim 6 (Withdrawn): A substrate processing apparatus comprising:

a processing chamber for accommodating a substrate therein;

a mounting table having a mounting portion for mounting thereon the substrate and a support for supporting the mounting portion;

a heating member disposed in the mounting portion, for heating the substrate;

a sealing member disposed between the support and the processing chamber; and

a shielding member for shielding a heat radiation directed toward the sealing member

from the mounting portion; and

a shielding cap covering a bottom portion of the support.

Claim 7 (Withdrawn): The apparatus of claim 6, wherein the shielding member covers at least a part of a bottom surface of the mounting portion.

Claim 8 (Withdrawn): The apparatus of claim 6, further comprising a substrate elevating member for elevating the substrate, wherein the shielding member supports the substrate elevating member.

Claim 9 (Withdrawn): The apparatus of claim 6, further comprising a processing gas supply system for supplying a processing gas into the processing chamber.

Claim 10 (Withdrawn): The apparatus of claim 9, wherein the processing gas supply system includes a plurality of processing gas supply units for supplying different processing gases and a processing gas supply unit controller for controlling each of the processing gas supply units such that the processing gases are supplied alternately.

Claim 11 (Canceled).

Claim 12 (Previously Presented): The apparatus of claim 1, wherein the cooling medium is water, hydrofluoroether, alcohol, fluorine-contained inactive liquid or naphthalene.

Claim 13 (Previously Presented): The apparatus of claim 1, wherein the casing includes a wick for moving the first cooling medium liquefied in the second end portion to the first end portion by a capillary force.

Claim 14 (Currently Amended): The apparatus of claim [[14]] 13, wherein the wick is a wire net.

Claim 15 (Previously Presented): The apparatus of claim 1, wherein the condenser includes a vessel for accommodating therein the second end portion.

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Claim 16 (Previously Presented): The apparatus of claim 15, wherein a circulation line for circulating a coolant which liquefies the vaporized cooling medium in the second end portion is connected to the vessel and a coolant supply source.

Claim 17 (Previously Presented): The apparatus of claim 16, wherein a pump for pumping the coolant from the coolant supply source is installed on the circulation line.

Claim 18 (Previously Presented): The apparatus of claim 3, wherein the temperature sensor is configured to be inserted into an aperture formed in the bottom portion of the processing chamber near the sealing member.

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